

## Electronic Acknowledgement Receipt

<b>EFS ID:</b>	3019209
<b>Application Number:</b>	09991196
<b>International Application Number:</b>	
<b>Confirmation Number:</b>	3908
<b>Title of Invention:</b>	HIGH DENSITY PLASMA CHEMICAL VAPOR DEPOSITION PROCESS
<b>First Named Inventor/Applicant Name:</b>	Chih-Chien Liu
<b>Customer Number:</b>	25235
<b>Filer:</b>	William H. Wright/Vivian Gutierrez
<b>Filer Authorized By:</b>	William H. Wright
<b>Attorney Docket Number:</b>	UMC-96-279 CON2
<b>Receipt Date:</b>	18-MAR-2008
<b>Filing Date:</b>	20-NOV-2001
<b>Time Stamp:</b>	19:11:29
<b>Application Type:</b>	Utility under 35 USC 111(a)

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Payment Type	Deposit Account
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RAM confirmation Number	3693
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## File Listing:

Document Number	Document Description	File Name	File Size(Bytes) /Message Digest	Multi Part /.zip	Pages (if appl.)
1	Miscellaneous Incoming Letter	818480016002trans.pdf	17890	no	1
			2754e9736b9e218e469c7dd02a274f96639f9aff		
Warnings:					
Information:					
2	Request for Continued Examination (RCE)	818480016002rce.pdf	44832	no	1
			58158d500a40cc2a6abbfbad48d050d2aec25871		
Warnings:					
This is not a USPTO supplied RCE SB30 form.					
Information:					
3	Amendment Submitted/Entered with Filing of CPA/RCE	818480016002amd.pdf	300374	no	11
			a180625ea14488a811118c90354433f2e0f52e52		
Warnings:					
Information:					
4	Terminal Disclaimer Filed	818480016002terdis.pdf	86880	no	3
			46cbacd0b2163b0368b42618926818ae050af1af		
Warnings:					
Information:					
5	Extension of Time	818480016002ext.pdf	26552	no	1
			9eb0f23af1299f8b956834b0535617e449445bd3		
Warnings:					
Information:					
6	Fee Worksheet (PTO-06)	fee-info.pdf	8471	no	2
			80ae00c95c249cba0d5cfb47f03d8ab530575c37		
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**New Applications Under 35 U.S.C. 111**

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

**National Stage of an International Application under 35 U.S.C. 371**

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.

**New International Application Filed with the USPTO as a Receiving Office**

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